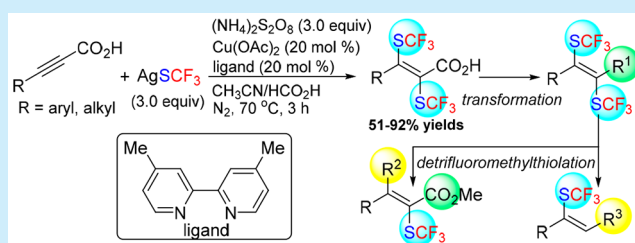


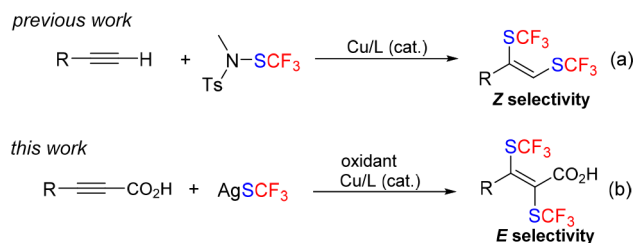
Copper-Catalyzed, Stereoselective Bis-trifluoromethylthiolation of Propiolic Acid Derivatives with AgSCF₃Shen Pan,[†] Huan Li,[†] Yangen Huang,[†] Xiu-Hua Xu,[‡] and Feng-Ling Qing^{*,†,‡,Ⓢ}[†]College of Chemistry, Chemical Engineering and Biotechnology, Donghua University, 2999 North Renmin Lu, Shanghai 201620, China[‡]Key Laboratory of Organofluorine Chemistry, Shanghai Institute of Organic Chemistry, Chinese Academy of Science, 345 Lingling Lu, Shanghai 200032, China**S** Supporting Information

ABSTRACT: A copper-catalyzed chemo- and stereoselective oxidative bis-trifluoromethylthiolation of propiolic acid derivatives was achieved by using carboxylic acid as the activating group and formic acid as a cosolvent. The reaction of propiolic acid derivatives and AgSCF₃ in the presence of (NH₄)₂S₂O₈ and catalytic Cu(OAc)₂ in MeCN/HCO₂H afforded bis-trifluoromethylthiolated acrylic acids in moderate to excellent yields with *E* selectivity. Further derivatization of the resultant products gave a series of polysubstituted SCF₃-containing alkenes.



The vicinal difunctionalization of alkenes and alkynes is a type of fundamentally important transformation and thus has been applied in different research areas.¹ Recently, the difunctionalization strategy has been widely applied in the preparation of fluorinated compounds² because of their increasing importance in various fields.³ Although the simultaneous introduction of a F,⁴ CF₃,⁵ or SCF₃⁶ with another functional group into alkenes and alkynes has made great progress, the vicinal difluorination and bis-trifluoromethylthiolation are quite limited.

In 2016, Jacobsen and Gilmour reported catalytic difluorination of alkenes with a nucleophilic fluoride source by I(I)/I(III) catalysis, respectively.⁷ The bis-trifluoromethylation of alkenes was recently developed by our group using CF₃SO₂Na in the presence of *t*-BuOOH/CuCl.⁸ In the case of bis-trifluoromethylthiolation, Tlili and Billard very recently disclosed a novel bis-trifluoromethylthiolation of electron-deficient or heteroatom-containing terminal alkynes with electrophilic TsNMeSCF₃ to give the bis-trifluoromethylthiolated alkynes with *Z* selectivity (Scheme 1a).⁹ However, this method suffers from the narrow substrate scope and low yields.

Scheme 1. Bis-trifluoromethylthiolation of Alkynes

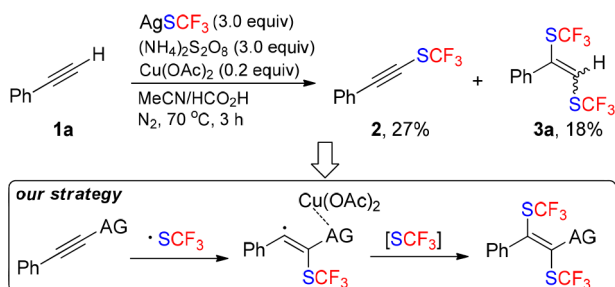
Herein, we describe an efficient and practical copper-catalyzed stereoselective oxidative bis-trifluoromethylthiolation of internal alkynes with nucleophilic AgSCF₃ using carboxylic acid as the activating group to form the bis-trifluoromethylthiolated products in high yields with *E* selectivity (Scheme 1b).

As an extension of our radical bis-trifluoromethylation of alkenes,⁸ we became interested in the analogous bis-trifluoromethylthiolation reactions. According to our experiences and other works,¹⁰ the readily available and stable AgSCF₃ is an ideal SCF₃ radical source. Thus, we initially investigated the bis-trifluoromethylthiolation of styrene or ethynylbenzene with AgSCF₃ in the presence of catalytic Cu(OAc)₂ and persulfates. No bis-trifluoromethylthiolated product was detected from the reaction of styrene. The bis-trifluoromethylthiolation of ethynylbenzene (**1a**) took place to give the bis-trifluoromethylthiolated product (**3a**) in 18% yield along with the formation of trifluoromethylthiolated alkyne **2** (Scheme 2) after screening of additives, oxidants, and solvents (see Table S1 in the Supporting Information (SI)), and it was also found that the use of HCO₂H as a cosolvent was crucial for bis-trifluoromethylthiolation reaction.

On the basis of this primary result, we next decided to introduce an activating group to the alkyne to improve the yield and chemoselectivity of bis-trifluoromethylthiolation reaction. We anticipated that the activating group would activate the alkyne to give higher yield and coordinate with the copper salt to form the bis-trifluoromethylthiolated product selectively. A series of activating groups, including ketone, ester, ether, carboxylic acid, and amide, were then investigated (Table 1).

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Scheme 2. Strategy of Introducing an Activating Group

Table 1. Optimization of Reaction Conditions^a

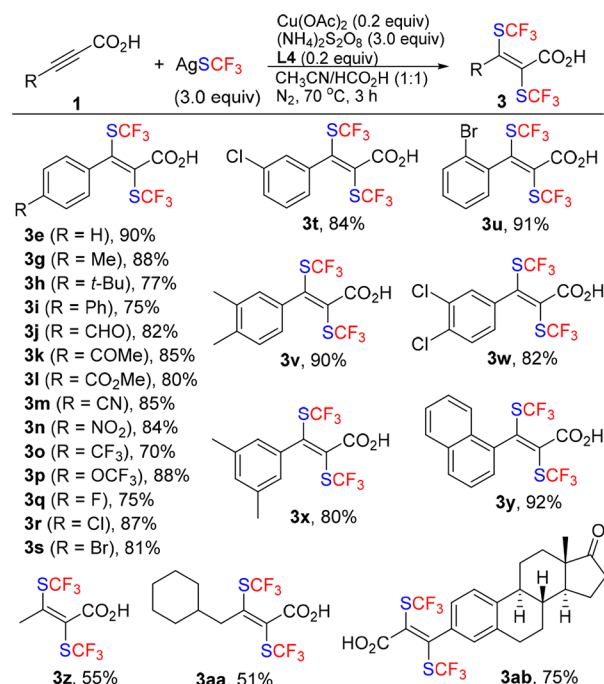
entry	1	Cu salt	ligand	yield ^b (%)	E/Z ^b (%)
1	1a	Cu(OAc) ₂		18	9:1
2	1b	Cu(OAc) ₂		trace	
3	1c	Cu(OAc) ₂		trace	
4	1d	Cu(OAc) ₂		15	9:1
5	1e	Cu(OAc) ₂		63	9:1
6	1f	Cu(OAc) ₂		20	9:1
7	1e	CuCl ₂		54	9:1
8	1e	CuI		49	9:1
9	1e	CuCN		32	9:1
10	1e	Cu(OAc) ₂	L1	85	>99:1
11	1e	Cu(OAc) ₂	L2	79	>99:1
12	1e	Cu(OAc) ₂	L3	72	>99:1
13	1e	Cu(OAc) ₂	L4	96	>99:1
14	1e	Cu(OAc) ₂	L5	60	>99:1
15	1e	Cu(OAc) ₂	L6	74	>99:1

^aReaction conditions: **1** (0.1 mmol), AgSCF₃ (0.3 mmol), Cu salt (0.02 mmol), (NH₄)₂S₂O₈ (0.3 mmol), ligand (0.02 mmol), MeCN/HCO₂H (1.5 mL/1.5 mL), under air, 70 °C, 3 h. ^bYields and stereoselectivities determined by ¹⁹F NMR spectroscopy using trifluoromethylbenzene as an internal standard.

The ketone and ester derivatives (**1b** and **1c**) were transformed into other CF₃S-containing products, but not the desired products (entries 2 and 3). The bis-trifluoromethylthiolation of alkynes **1d** and **1f** afforded the desired products in low yields (entries 4 and 6). Interestingly, the acid derivative (**1e**) gave the bis-trifluoromethylthiolated product **3e** in 63% yield (entry 5). The employment of carboxylic acid as an activating group has been well studied in C–H bond functionalization reactions.¹¹ Herein, the carboxylic acid was a powerful activating group for difunctionalization reactions. To improve the yield of compound **3e** further, copper salts and ligands were examined. Switching Cu(OAc)₂ into other Cu salts including CuCl₂, CuI, and CuCN led to lower yields (entries 7–9). In general, the addition of catalytic monodentate or bidentate ligand was

beneficial for yield and stereoselectivity (entries 10–15). Among the ligands (**L1**–**L6**) tested, 4,4'-dimethyl-2,2'-bipyridine (**L4**) afforded **3e** in highest yield (96%) with excellent stereoselectivity (*E/Z* > 99:1) (entry 13). Moreover, when the reaction was carried out in the presence of other oxidants such as PhI(OAc)₂ and 2,3-dichloro-5,6-dicyano-1,4-benzoquinone (DDQ), none of the desired product **3e** was detected. It was noteworthy that product **3e** was confirmed as the *trans*-addition product by the X-ray crystallographic analysis (see the SI), which is in contrast to Tlili and Billard's work on the *cis*-bis-trifluoromethylthiolation of alkynes.⁹

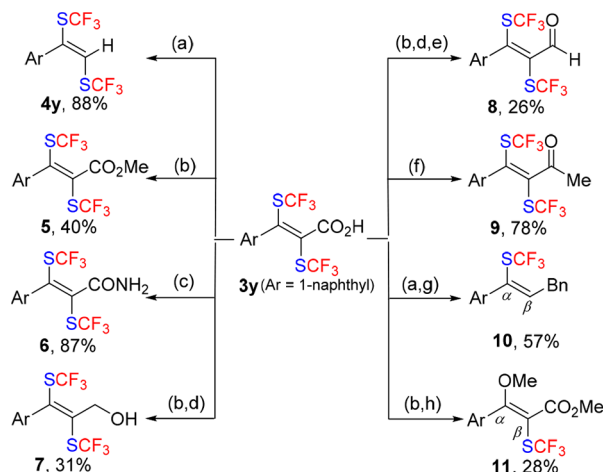
The scope of the bis-trifluoromethylthiolation of propiolic acid derivatives is shown in Scheme 3. The aromatic propiolic

Scheme 3. Bis-trifluoromethylthiolation of Propiolic Acid Derivatives^a

^aReaction conditions: **1** (0.2 mmol), AgSCF₃ (0.6 mmol), Cu(OAc)₂ (0.04 mmol), (NH₄)₂S₂O₈ (0.6 mmol), **L4** (0.04 mmol), MeCN/HCO₂H (3.0 mL/3.0 mL), under N₂, 70 °C, 3 h, isolated yields.

acids were transformed into the bis-trifluoromethylthiolated acrylic acids in good to excellent yields. Substrates bearing electron-donating (**1g**–**1i**) and electron-withdrawing (**1j**–**1p**) groups as well as halides (**1q**–**1s**) were all effective. The position and number of substitutions (**1t**–**1y**) did not interfere with this transformation. In the cases of aliphatic propiolic acids (**1z** and **1aa**), the desired products (**3z** and **3aa**) were obtained in moderate yields. Notably, this protocol could also be applied for complex molecules such as estrone derivative (**1ab**) to give the bis-trifluoromethylthiolated product (**3ab**) in good yield.

Compounds that contain a bis-SCF₃-substituted acrylic acid moiety are useful precursors for the preparation of SCF₃-containing compounds. As shown in Scheme 4, the decarboxylation of compound **3y** in CH₃CN at 90 °C proceeded smoothly to afford **4y** in high yield. Moreover, **3y** was subjected to several standard transformations to give bis-trifluoromethylthiolated α,β-unsaturated ester (**5**), amide (**6**), aldehyde (**8**), and ketone (**9**) and as well as allylic alcohol (**7**). The trifluoromethylthio group was proven to be a good leaving

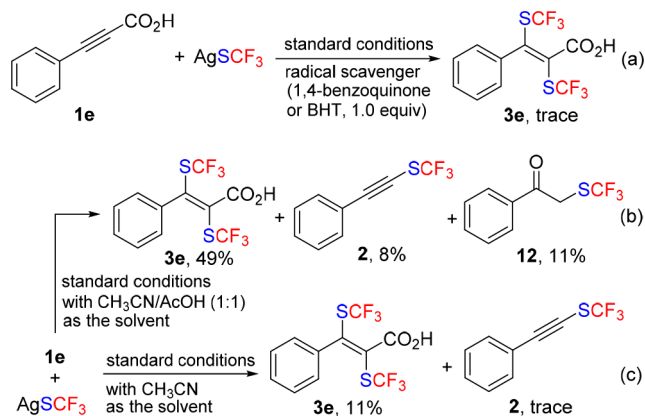
Scheme 4. Transformation of Compound 3y^a

^aReaction conditions: (a) CH₃CN, 90 °C, 2 h; (b) H₂SO₄, MeOH, 100 °C, 24 h; (c) SOCl₂, rt, 4 h; then NH₃/H₂O, 0 °C to rt, 30 min; (d) DIBAL-H, CH₂Cl₂, -78 °C, 3 h; (e) MnO₂, CH₂Cl₂, reflux, 24 h; (f) SOCl₂, rt, 4 h; then AlMe₃, CH₂Cl₂; (g) BnMgCl, THF, 0 °C, 2 h; (h) NaOMe, THF, 0 °C, 2 h.

group when bis-trifluoromethylthiolated alkene was subjected to nucleophiles. For example, treatment of compound 4y with BnMgCl gave α -CF₃S-substituted naphthyl alkene (10). On the other hand, the substitution of compound 5 by NaOMe afforded β -CF₃S-substituted naphthyl alkene (11). These unique detrifluoromethylthiolation reactions probably proceed through a nucleophilic addition followed by the elimination of trifluoromethanethiolate.

To gain mechanistic insights into this reaction process, some preliminary studies were conducted. Only a trace of the desired product was detected when a radical scavenger, 1,4-benzoquinone or 2,6-di-*tert*-butyl-4-methylphenol (BHT), was added to the reaction mixture (Scheme 5a), which indicated

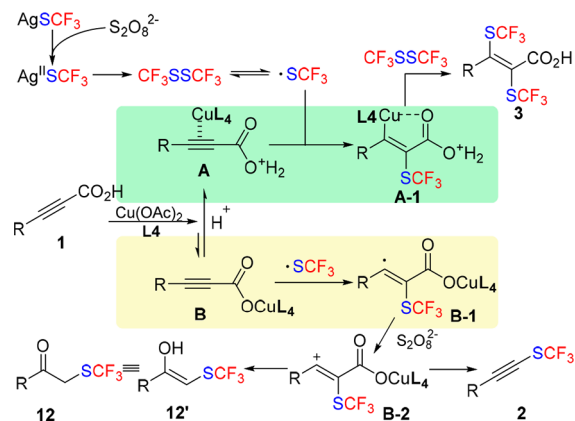
Scheme 5. Preliminary Mechanistic Studies



this transformation probably proceeded through a radical pathway. Moreover, the reaction in MeCN/AcOH gave 3e in 49% yield along with the decarboxylation products, trifluoromethylthiolated alkyne (2) and α -trifluoromethylthiolated ketone (12), in low yields (Scheme 5b).¹² Compound 3e was formed in only 11% yield when the reaction was performed in MeCN (Scheme 5c). These results revealed the importance of HCO₂H in this reaction.

On the basis of the above results, a plausible reaction mechanism was proposed (Scheme 6). First, oxidation of

Scheme 6. Proposed Reaction Mechanism



AgSCF₃ by (NH₄)₂S₂O₈ generates Ag^{II}SCF₃, which could be further transformed to CF₃S radical or CF₃SSCF₃.¹⁰ In fact, we could detect the formation of CF₃SSCF₃ in the reaction mixture by ¹⁹F NMR spectroscopy. On the other hand, substrate 1 is transformed into copper complexes A⁹ and B.^{12a,d} There is an equilibrium between A and B, which is affected by the acidity of the reaction mixture. In formic acid, complex A is primary and reacts with CF₃S radical to generate possible intermediates A-1. Finally, the copper-assisted trifluoromethylthiolation with CF₃SSCF₃ affords products 3. In less acidic solution, the addition of CF₃S radical to complex B produces the radical intermediate B-1, which is further oxidized to cationic intermediate B-2. Compound B-2 may undergo decarboxylation or nucleophilic attack/decarboxylation to give the byproducts 2 and 12. However, the exact mechanism of this transformation remains unclear at the present stage.

In conclusion, we have disclosed an unprecedented copper-catalyzed, oxidative bis-trifluoromethylthiolation of propiolic acid derivatives with AgSCF₃. The use of HCO₂H as the cosolvent was crucial for this reaction. The resulting bis-trifluoromethylthiolated acrylic acids and their derivatives are previously unknown, difficult to obtain by other methods, and potentially useful in drug discovery and material science. Further investigation of the reaction mechanism and the applications of bis-trifluoromethylthiolated products are currently in progress in our laboratory.

■ ASSOCIATED CONTENT

Supporting Information

The Supporting Information is available free of charge on the ACS Publications website at DOI: 10.1021/acs.orglett.7b01366.

Table S1, experimental procedures, characterization data, mechanistic study data, ¹H, ¹⁹F, and ¹³C NMR spectra, and X-ray crystal structure of 3-e (PDF)

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Notes

The authors declare no competing financial interest.

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